

REMARKS

Claims 33-47 are pending in this application. By this Amendment, claims 33, 34, 35, 39 and 40 are amended. Claim 47 is added. The claim amendments and added claims introduce no new matter. Reconsideration of the application based on the above amendments and the following remarks is respectfully requested.

The Office Action, in paragraph 1, objects to claim 40 because of an informality. claim 40, and in like manner claim 39, are amended to obviate the objection. Withdrawal of the objection to claim 40 is respectfully requested.

The Office Action, also in paragraph 1, objects to claim 34 as being apparently duplicative of claim 33. This objection is respectfully traversed. Claim 33 presents a method based on at least Figs. 1A-3D, in which a first impurity portion 23 has three portions. A first portion of the first impurity portion 23 overlaps with gate electrode 19. A second portion of the first impurity portion protrudes into source region 17. A third portion of the first impurity portion protrudes into drain region 18. Claim 34 differs from claim 33 in that claim 34 presents a method based on at least Figs. 8 and 9. Here, a first impurity portion 71 overlaps with a gate electrode 19, and no portion of the first impurity portion 71 is not overlapping with the gate electrode 19. Claim 35 further differs from either of claims 33 or 34 in that one first impurity portion is separated into at least two portions by the intrinsic portion. Withdrawal of the objection to claim 34 is respectfully requested.

The Office Action, in paragraph 2, rejects claims 33-36, 41, 42, 45 and 46 under 35 U.S.C. §102(e) as being anticipated by U.S. Patent No. 5,830,787 to Kim. The Office Action, in paragraph 3, rejects claims 43 and 44 under 35 U.S.C. §103(a) as being unpatentable over Kim taken with U.S. Patent No. 5,016,986 to Kawashima et al. (hereinafter "Kawashima"). The Office Action, in paragraph 4, rejects claims 37-40 under

35 U.S.C. §103(a) as being unpatentable over Kim taken with U.S. Patent No. 5,569,935 to Takemura et al. (hereinafter "Takemura"). These rejections are respectfully traversed.

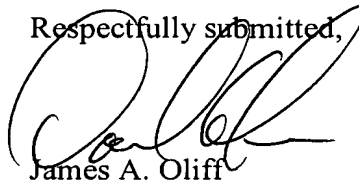
Kim teaches a method of manufacturing a transistor. Kim, however, does not teach, nor can it reasonably be considered to have suggested, any of the specific combinations of features recited in any of claims 33-35 as specifically referenced above. Neither of Takemura nor Kawashima is applied in a manner that would overcome these shortfalls in the application of Kim to the subject matter of claims 33-35. In other words, neither of Kawashima or Takemura teaches, nor can they reasonably be considered to have suggested, the specific feature referenced above, as recited in claims 33-35.

For at least these reasons, Kim taken alone, or in combination with Kawashima and/or Takemura, cannot reasonably be considered to teach, or to have suggested, the subject matter of the pending claims. Accordingly, reconsideration and withdrawal of the rejections of claims 33-46 under 35 U.S.C. §102(e) as being anticipated by Kim, or under 35 U.S.C. §103(a) as being unpatentable over Kim taken with either of the other applied prior art reference are respectfully requested.

In view of the foregoing, Applicant respectfully submits that this application is in condition for allowance. Favorable reconsideration and prompt allowance of claims 33-47 are earnestly solicited.

Should the Examiner believe that anything further would be desirable in order to place this application in even better condition for allowance, the Examiner is invited to contact Applicant's undersigned representative at the telephone number set forth below.

Respectfully submitted,



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